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VERIFICATION OF TRANSLATION

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I verify that the attached English translation is a true and correct translation made by me of the attached specification in the German language of International Application PCT/EP03/00679;

I further declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment or both under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.

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Process for the production of a plate

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The invention concerns a process for the production of a plate, in particular a motor vehicle licence plate, of the kind set forth in the classifying portion of claim 1, and plates produced in accordance with that process.

10 Reflective plates, in particular motor vehicle licence plates, are known from the state of the art, the reflectance of which is based on a reflection film being glued or laminated on to a carrier which for example comprises sheet aluminum. In that situation it is necessary to use reflection  
15 films whose reflectance is within a range which is fixed by statute and which establishes that the reflectance may not fall below a minimum value of that range or exceed a maximum value thereof. Commercially available films which satisfy those conditions include a carrier layer which frequently comprises aluminum and which is impenetrable for light.

If now the attempt is made to produce a plate, in particular a motor  
20 vehicle licence plate, which is self-illuminating by virtue of the fact that, on one of its flat sides, it has a layer sequence which forms an electroluminescence flat capacitor and which is constructed directly on the plate itself, then in accordance with the state of the art such a plate cannot be at the same time designed to be reflective. More specifically, if the layer  
25 sequence of the flat capacitor is firstly applied to the carrier, it cannot then be covered over with the above-mentioned reflection films as the carrier thereof does not transmit the light which it emits.

If conversely the attempt is made to apply a surface-covering electroluminescence flat capacitor arrangement to the top side of a  
30 reflection film applied to the plate carrier, the reflection properties thereof become ineffective as at least some of the flat capacitor layers are impenetrable in both directions in relation to external light.

Admittedly transparent reflection films are also available on the market, but they have a reflectance which is substantially higher than the above-mentioned maximum value which is permitted by statute.

In comparison therewith the object of the present invention is to  
5 provide a process of the kind set forth in the opening part of this specification, which makes it possible easily and inexpensively to produce plates, in particular motor vehicle licence plates, which have a reflectance complying with the statutory requirements and which at the same time carry an electroluminescence flat capacitor which covers at least the major  
10 part of the flat side thereof and which imparts self-illuminating properties thereto.

To attain that object, the invention provides the features recited in claim 1.

Those measures are based on the consideration that it is possible to  
15 apply both a layer sequence forming an electroluminescence flat or surface capacitor and also a reflective film to one and the same side of the carrier, if a reflection film is used, whose reflectance is initially higher than the maximum value permitted by statute, but that reflection foil is subjected to at least one manufacturing step which at least in location-wise manner  
20 reduces its reflectance to such an extent as to afford an average value which complies with the statutory requirements.

Basically, two different operating procedures are possible when carrying out the method according to the invention as set forth in claim 1.

In one procedure firstly as set forth in claim 16 the reflective foil is  
25 applied to the carrier of the plate and, on the front side of said film which faces towards the person viewing it, there is constructed a rastered flat capacitor arrangement, the size and the surface density of the electrically conducting interconnected raster points which are impermeable to external light being so selected that they cover a sufficient area of the  
30 reflection film to reduce the mean reflection value thereof to below the maximum value permitted by statute and at the same time form a sufficiently large area which lights up in operation to satisfy the statutory requirements in terms of brightness of a self-illuminating plate. It has

surprisingly been found that such a choice in terms of size and surface density is possible. With this variant it is immaterial whether the reflection film has an opaque carrier layer or not.

5 In a more greatly preferred variant however as set forth in claim 2 firstly the layer sequence forming the flat capacitor is built up on the carrier of the plate and then covered over with a reflection film which from the outset is transparent or is made transparent in a location-wise manner, for the light emitted in operation by the flat capacitor.

10 In order to reduce the initially very high reflection value of such a film to bring it into the permissible range, a plurality of different process steps which are independent of each other or which can be used in conjunction with each other are available in accordance with the invention.

15 In accordance with a particularly preferred mode of operation a transparent reflection film, at the rear side of which prismatic structures freely project, at the interfaces of which the light incident from the front side is reflected by total reflection, is so connected to a layer which is applied to the top side of the flat capacitor and which preferably at the same time serves as an adhesive for the reflection film and which involves approximately the same refractive index as the prismatic structures of the reflection film, that the free spaces present between the projecting  
20 prismatic structures are at least partially filled by said layer. No further total reflection can then occur at all the interfaces of the prismatic structures which are covered by that layer. By virtue of the fact that not all interfaces of the prismatic structure are brought into contact with that layer, there is still a reflectance - although reduced - which can be  
25 controlled within wide limits and in particular in such a way that the statutory standards are satisfied, by virtue of the extent to which the prismatic structures are covered by the above-mentioned layer.

30 That extent can be specifically and targetedly influenced by virtue of the production process being of a suitable nature, as is set forth in appendant claims 4 through 9.

In accordance with another preferred process, as set forth in appendant claims 10 through 15, a transparent reflection film is tempered,

that is to say heated, either prior to or during the application to the uppermost layer of the flat capacitor or a transparent layer disposed thereover, and/or is pressed against a hard flat surface in such a way that the prismatic structures projecting at the rear side thereof are flattened off  
5 and thus there is a reduction in the surface regions of said structures, which implement total reflection. By virtue of suitable selection of the temperature and/or the pressing pressure as well as the treatment time, it is in turn possible to reduce the reflectance of the reflection film to such an extent that it is in the range permitted by statute.

10 A further preferred possibility, as set forth in claim 3, involves applying a reflection film which is not transmissive in respect of the light of the electroluminescence flat capacitor on or over the electroluminescence flat capacitor which is provided with a raster pattern of holes in which the size and surface density of the through holes are so selected that the  
15 reduction implemented thereby in respect of the reflection value which is averaged in relation to surface area reduces same to below the permitted maximum value and at the same time affords adequate options for transmission of the light emitted by the flat capacitor in operation, in order to be able to satisfy the statutory brightness requirements.

20 The features of plates which are produced in accordance with one of the processes of the invention are set forth in appendant claims 17 through 25.

The invention is described hereinafter by means of embodiments by way of example with reference to the drawing in which:

25 Figure 1 shows a diagrammatic cross-section through a first embodiment of a plate according to the invention in which the degree of reflection of a transparent reflection film is reduced by partially immersing the prismatic structures projecting on the rear side in an adhesive layer having the same refractive index,

30 Figure 2 shows a diagrammatic cross-section through a second embodiment of a plate according to the invention in which the degree of reflection of a transparent reflection film is reduced by completely immersing the prismatic structures projecting on the rear side in an

adhesive layer which is only partially applied to the surface of the plate and having the same refractive index,

Figure 3 shows a diagrammatic cross-section through a third embodiment of a plate according to the invention in which the degree of reflection of a reflection film having a non-transparent carrier is reduced by  
5 applying a grid raster of holes which pass through to the electroluminescence flat capacitor, and

Figure 4 shows a diagrammatic cross-section through a fourth embodiment of a plate according to the invention in which the degree of reflection of a transparent reflection film is reduced by flattening or  
10 rounding of the prismatic structures projecting on the rear side.

In all illustrated embodiments the thicknesses of the individual layers are not shown true to scale and in part, for the sake of simplicity, are illustrated on a greatly enlarged scale. The prismatic structures which project from the rear side of the reflection film or which are embedded into  
15 the reflection film and at the interfaces of which reflection of the light incident from the front, that is to say from above in the Figures, are shown in greatly simplified form as rearwardly projecting prisms of triangular or trapezoidal cross-section.

20 In the lower region all illustrated embodiments involve the same layer structure. Those layers which are the same in all of Figures 1 through 4 are denoted by the same references.

The basis of each plate is formed by a deformable carrier 1 which can comprise a plastically deformable plastic material or metal, for example  
25 aluminum. In the latter case the carrier 1 is preferably completely covered over by an insulating layer 2 which on its top side carries a metal coating which is a good electrical conductor, for example of copper, and out of which are etched various conducting regions of which the Figures show in cross-section only the region forming the base electrode 4 of the  
30 electroluminescence flat capacitor described hereinafter. If a plurality of mutually juxtaposed, separately actuatable flat capacitors are to be provided on the plate, then a plurality of mutually electrically insulated base electrodes with their respective actuating lines can also be etched out of

the metal coating. In addition, a feed-in line (not shown) for the transparent cover electrode of the flat capacitor or capacitors, said electrode being described in greater detail hereinafter, is also advantageously etched out of the metal coating in such a way that it is electrically insulated from the base electrode or electrodes and the actuating lines thereof.

Disposed over the metal coating is an insulating layer 5 which covers the entire surface of the base electrode 4 and which is preferably colored with a light pigment so that the light which is emitted rearwardly, that is to say downwardly in the Figures, by the pigment layer 6 disposed thereabove in operation of the flat capacitor is radiated as completely as possible forwardly. Disposed over the pigment layer is a transparent, extremely thin cover electrode 7 which however is a good electrical conductor and which, in at least one edge region (not shown in the Figures) in which the insulating layer 5 and the pigment layer 6 are omitted, is in good electrically conducting contact with the feed-in line which is produced from the metal coating so that an ac voltage can be applied by way of that feed-in line to the cover electrode 7 in relation to the base electrode 4, by virtue of which voltage the doped pigments contained in the pigment layer 6 are excited in known manner to produce a light referred to as electroluminescence.

The structures described hereinbefore can be produced by a procedure whereby a commercially available film which forms the insulating layer 2 and which is provided on its underside with an adhesive layer (not shown) and which on its top side carries the metal coating is glued or laminated on to the carrier 1. The operation of etching out the various, electrically mutually separated line and electrode regions can be effected as required prior to or after that operation of applying the plastic film to the carrier 1. The further layers 4 through 7 of the flat capacitor can be applied by known coating processes (spraying, screen printing, thick layer or other coating processes).

In the embodiment shown in Figure 1, disposed over the transparent cover layer 7 is a comparatively thick adhesive layer 9 which is applied over

the entire flat side of the plate and which serves for fixing the reflection film 10 disposed thereover. The adhesive used for the adhesive layer 9 at least in the hardened final condition has a refractive index which is substantially equal to the refractive index of the prismatic structures 12 projecting from the rear side of the reflection film 10. When applying the reflection film 10 it is pressed under a predetermined pressure in such a way that those prismatic structures 12 penetrate to a desired depth into the adhesive layer 9. For all light beams which impinge on the transparent reflection film 10 from the front, that is to say from above in the Figures, and which are propagated therethrough into the prismatic structures 12, no or only a greatly reduced level of total reflection occurs at the surface portions of the prismatic structures 12 which are covered by the adhesive of the adhesive layer 9, because of the equal or almost equal refractive indices; total reflection however is retained unreduced at the surface portions of the prismatic structures 12, which are not covered by adhesive. On average therefore that affords a reflectance on the part of the reflection film 10, which is reduced in comparison with the non-adhesive-coated condition thereof. The extent of the reduction in the reflectance depends on the depth of immersion of the prismatic structures 12 into the adhesive layer 9, which in turn can be controlled by the pressure exerted in the operation of applying the reflection film 10 and/or the viscosity of the adhesive which prevails at the time of applying the reflection film. It is thus possible to use a reflection film 10 which is very substantially transparent for the light of the flat capacitor or capacitors and which, prior to processing thereof, has a very high reflectance which is above the maximum value permitted by statute, that reflectance being reduced in a specific targeted fashion in production of the plate in such a way that it falls in the range which is permitted by statute.

The embodiment shown in Figure 2 only differs from that shown in Figure 1 in that the adhesive layer 9 is not applied over the entire surface area but only partially to the top side of the transparent cover electrode 7 and that the prismatic structures 12 projecting at the rear side of the reflection film 10, in the surface regions in which there is an adhesive layer



9, are immersed completely into same so that the free spaces between them are entirely filled with adhesive. Therefore, no total reflection whatsoever takes place in those regions at the adhesive-covered surfaces of the prismatic structures 12. In contrast, in the surface regions in which  
5 there is no adhesive layer 9, the prismatic structures 12 retain their capability of total reflection to the full extent. Accordingly, by virtue of a suitable choice both of the size and also the distribution of the surface regions which are covered with an adhesive layer 9 and the adhesive-free surface regions disposed therebetween, it is possible to achieve a mean  
10 reflectance in respect of the reflection film 10, which is within the range permitted by statute, although the reflectance of the reflection film 10 before processing exceeds the maximum permissible limit value.

The adhesive layer 9 can be applied in different ways both in the embodiment of Figure 1 and also in the embodiment shown in Figure 2.

15 One possible way involves using a screen printing process which makes it possible quickly and reliably to implement both application over the entire surface area as shown in Figure 1 and also the application limited to individual surface regions, with interposed adhesive-free surface regions, in an economical fashion.

20 Another process involves using a transfer film which is covered on one side with an adhesive layer or an adhesive pattern and which is pressed with that layer leading against the uppermost layer of the flat capacitor or a layer covering the flat capacitor in order to transfer the adhesive on to that layer. Thereafter, the transfer film is detached and the  
25 reflection film is applied.

Another possibility involves using an adhesive film which is coated with adhesive on both sides, wherein the adhesives on the two flat sides of the adhesive film can be the same or, adapted to the specific conditions involved, can be different from each other. Thus, particularly in the case  
30 shown in Figure 2, the lower adhesive layer is distributed over the entire surface area while only individual surface elements are covered with adhesive on the top side of the adhesive film. The layer thicknesses of the adhesives on the two sides of the adhesive film can be the same or

different from each other. Using the lower adhesive layer, the adhesive film is stuck on to the uppermost layer of the flat capacitor or a layer covering same, while the reflection film is glued on to the top side of the adhesive film. As the adhesive film remains in the layer structure of the plate, it  
5 must be transparent in relation to the light emitted by the flat capacitor in operation.

The embodiment shown in Figure 3 uses a reflection film 10' which comprises three layers, namely a foremost transparent cover layer 14 which in turn includes prismatic structures 12 which are completely  
10 embedded into an intermediate layer 15 which is also transparent and the refractive index of which differs from that of the prismatic structures 12 so greatly that total reflection occurs at the interfaces. The reflection film 10' further includes a carrier layer 16 comprising a material which is not transparent for the light of the subjacent flat capacitor 4 through 7, for  
15 example aluminum, which is stuck by means of an adhesive layer (not shown) on to the top side of the transparent cover layer 7 or laminated thereon in some other fashion.

In order here to reduce in the required fashion the initially very high reflectance of the reflection film 10', which is above the statutory limit  
20 value, the reflection film 10' is provided with a grid raster of through holes 19, that is to say holes which extend through all layers 14 through 16, only some of the holes being shown in Figure 3. The diameter and the surface density of the holes 19 are on the one hand so selected that the reflectance of the reflection film 10' is reduced in the required fashion and at the same  
25 time sufficient light can issue from the flat capacitor 4 through 7 forwardly (that is to say upwardly in the Figures) in order to satisfy the statutory requirements in regard to the brightness of an illuminated plate, in particular a motor vehicle licence plate.

The embodiment illustrated in Figure 4 again uses a reflection film 10  
30 which is transparent in relation to the light of the flat capacitor 4 through 7 and from the rear side of which the prismatic structures 12 freely project. It is stuck on to the top side of the transparent cover electrode 7 with a thin adhesive layer 20 which here does not penetrate into the intermediate

spaces between the prismatic structures 12. In order nonetheless to achieve the required reduction in the reflectance of the reflection film 10, those prismatic structures 12 are flattened off or rounded in such a way that, in the cross-section in Figure 4, they are of a substantially trapezoidal configuration, whereby their surface regions permitting total reflection are reduced in size.

Flattening or rounding of the prismatic structures 12 can be effected by the film 10 being heated and pressed against a hard surface under a predetermined pressure. The extent of the flattening or rounding effect can be controlled by the level of the temperature used and/or the magnitude of the pressing pressure. It will be appreciated that, the more the prismatic structures 12 are flattened off, the greater will be the reduction in the reflectance of the film 10.

Depending on the respective nature of the reflection film used however it may also be sufficient for it just to be heated to an elevated temperature for a given period of time in order to achieve the desired flattening or rounding of the prismatic structures, without pressure having to be applied at the same time to the film or the prismatic structures.

When using other films, it may be sufficient only to exert a given pressure on the prismatic structures without in that respect specifically increasing the temperature. In this case also the period of time and the magnitude of the pressure can be employed as control parameters.

In all those cases, the operation of heating and/or pressing the film 10 can be effected either in a separate step in the process prior to the application thereof to the cover electrode 7 or a layer covering same, or during that application procedure.

All the illustrated embodiments may include additional layers, in particular protective layers for covering the outward sides, which are not shown in the Figures. As an alternative to the embodiment shown in Figure 1 it is also possible to apply pressure to the transparent reflection film 10 in such a way that the tips of the prismatic structures which project at the rear side thereof penetratingly advance as far as the cover electrode 7 or a transparent hard layer (not shown) disposed thereover, but substantially

cannot deform same, because of its hardness. In that case the thickness of the adhesive layer 9 which is completely pierced by the prismatic structures 12 is so selected that it only partially fills in respect of height the free spaces present between those prismatic structures, and thus reduces the reflectance of the reflection film 10 not completely but to the desired extent.

The measures described hereinbefore by means of the embodiments by way of example in Figures 1 and 2 can also be adopted in combination. It is also possible to provide adhesive layers of differing thicknesses in different surface regions, those adhesive layers filling to different heights the free spaces between the prismatic structures 12.

Another possibility involves applying the layers of the flat capacitor not under the reflection film 10 or 10' but on the top side thereof which is towards the person viewing the arrangement, in rastered form. As those layers do not transmit any light to the reflection film 10 or 10' or light reflected thereby cannot issue through the top side, a suitable choice in respect of the size and surface density of the electrically conductively interconnected raster points of the flat capacitor arrangement reduces the mean reflectance of the reflection film 10 or 10' in the desired manner and at the same time achieves the required brightness of the flat capacitor arrangement. In that case it is possible to use both completely transparent reflection films 10 and also reflection films 10' which include an opaque layer.